

IPW

LEE0023-US

PATENT



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:

SHIH-CHANG CHANG ET AL.

Serial No.: 10/690,703

Filed: October 23, 2003

For: SEMICONDUCTOR DEVICE WITH
LIGHTLY DOPED DRAIN AND
METHOD OF MANUFACTURING
THE SAME

Art Unit: 2814

Examiner: PERALTA, GINETTE

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Applicants wish to make of record in the above-identified application the document or documents referenced on the attached Form PTO-1449. A copy of each non U.S. reference is enclosed herewith.

The cited reference is mentioned in an Examination Report received from the Chinese Patent Office in applicant's corresponding Chinese patent application and is believed relevant for at least that reason.

The undersigned believes that this Information Disclosure Statement is being filed before the mailing date of a first Office Action on the merits for the above-referenced application. Accordingly, Applicants do not believe that a fee is due for filing this paper. However, should a first action on the merits have been issued on the same day or before this Information Disclosure

Serial No.: 10/690,703
Art Unit: 2814
Inventor: Shih-Chang CHANG et al.

Attorney's Docket No.: LEE0023-US
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Statement is filed, please accept this Information Disclosure Statement under Rule 97(c) and charge the requisite Rule 17(p) fee to our Deposit Account No. 03-3975, under Order No. LEE0023-US and proceed to consider this Information Disclosure Statement.

It is respectfully requested that the information be expressly considered during the prosecution of this application, and that each reference be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This submission does not represent that any referenced document is material or constitutes "prior art." If it should be determined that one or more of the referenced documents constitute "prior art" under United States law, Applicants reserve the right to present to the Office the relevant facts and law regarding the appropriate status of the reference or references.

Applicants further reserve the right to take appropriate action to establish the patentability of the disclosed invention over any referenced document, should it be applied against the claims of the present application.

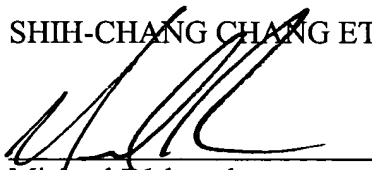
PILLSBURY WINTHROP SHAW PITTMAN LLP
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Respectfully submitted,

SHIH-CHANG CHANG ET AL.

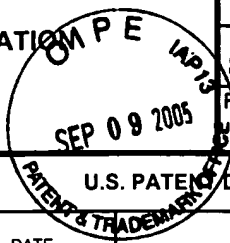
Date: September 9, 2005

By:


Michael Bednarek
Registration No. 32,329

MB/LDE/ggb

Customer No. 28970

INFORMATION DISCLOSURE CITATION <i>(Use several sheets if necessary)</i>				ATTY DOCKET NO. LEE0023-US		SERIAL NO. 10/690,703	
				SHIH-CHANG CHANG ET AL.			
				FILING OCTOBER 23, 2003		GROUP 2814	
				U.S. PATENT DOCUMENTS			

*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

FOREIGN PATENT DOCUMENTS								
		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							YES	NO
		11-097703	04/09/1999	JAPAN				✓

OTHER DOCUMENTS <i>(Including Author, Title, Date, Pertinent Pages, Etc.)</i>			
			ENGLISH LANGUAGE ABSTRACT OF JP 11-097703

EXAMINER	DATE CONSIDERED
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.